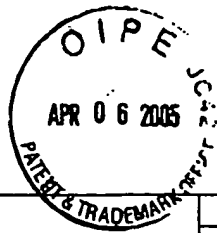



Appl. no. 09/527,931
IDS dated April 4, 2005



Modified Form PTO/SB/08A

INFORMATION DISCLOSURE STATEMENT BY APPLICANT (use as many sheets as necessary)		<i>Complete If Known</i>			
		Application Number	09/527,931		
		Filing Date	March 17, 2000		
		First Named Inventor	Mathieu et al.		
		Group Art Unit	3729		
		Examiner Name	Rick K. Chang		
Sheet	1	of	1	Attorney Docket No.	P114-US

FOREIGN PATENT DOCUMENTS								
Examiner Initials ¹	Cite No. ¹	Foreign Patent Document			Name of Patentee or Applicant	Publ. Date	T ⁶	Copy Enclosed
		Office ²	Number ³	Kind Code ³				
	1.	JP	05-264590		Mori	10/12/1993	x	Yes

Examiner Signature	<i>[Signature]</i>	Date Considered	6/27/05
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* EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication

¹Unique citation designation number. ²See attached Kinds of U.S. Patent Documents. ³Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3). ⁴For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST.16 if possible. ⁶Applicant is to place a check mark here if English language Translation is attached.

** Reference cited in parent application US Serial No. ___. 37 CFR § 1.98(d)

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